

United States of America

United States Patent and Trademark Office

PICOSUN

Reg. No. 4,296,791

Registered Mar. 05, 2013

Amended Jul. 30, 2024

Int. Cl.: 7, 9, 40

Service Mark

Trademark

Principal Register

Picosun Oy (FINLAND LIMITED LIABILITY COMPANY)

Tietotie 3

Espoo, FINLAND FI-02150

CLASS 7: Machines and machine tools for atomic scale layer deposition; atomic scale layer deposition apparatus, namely, industrial chemical [and industrial photochemical] reactors; reactor systems consisting of several industrial chemical [and industrial photochemical] reactors, precursor sources, inactive gas sources, plasma sources, source units, loading units, lift units, substrate holders, deposition cartridges, diffusion enhancers, gas treatment units, particle traps, water cooling units and chillers, all of which are sold as an integral part of the atomic scale layer deposition industrial chemical [and industrial photochemical] reactors; and reactor systems consisting of several industrial chemical [and industrial photochemical] reactors as described above

CLASS 9: Data processing equipment; computers and computer programmes for controlling and monitoring atomic scale layer deposition apparatus, namely, reactors and reactor systems consisting of several reactors, for collecting data from aforementioned atomic scale layer deposition apparatus, user interface software for aforementioned atomic scale layer deposition apparatus, computer software enabling aforementioned atomic scale layer deposition apparatus to interface and communicate with devices used in connection with aforementioned atomic scale layer deposition apparatus, computer software for controlling and monitoring devices used in connection with aforementioned atomic scale layer deposition apparatus

CLASS 40: Treatment and coating of materials by atomic scale layer deposition method and consulting connected thereto

PRIORITY DATE OF 08-16-2011 IS CLAIMED

OWNER OF INTERNATIONAL REGISTRATION 1099114 DATED 08-17-2011,
EXPIRES 08-17-2031

The wording "PICOSUN" has no meaning in a foreign language.

SER. NO. 79-106,107, FILED 08-17-2011

Katherine Kelly Vidal

Director of the United States
Patent and Trademark Office



REQUIREMENTS TO MAINTAIN YOUR FEDERAL TRADEMARK REGISTRATION

WARNING: YOUR REGISTRATION WILL BE CANCELLED IF YOU DO NOT FILE THE DOCUMENTS BELOW DURING THE SPECIFIED TIME PERIODS.

Requirements in the First Ten Years*

What and When to File:

- **First Filing Deadline:** You must file a Declaration of Use (or Excusable Nonuse) between the 5th and 6th years after the registration date. See 15 U.S.C. §§1058, 1141k. If the declaration is accepted, the registration will continue in force for the remainder of the ten-year period, calculated from the registration date, unless cancelled by an order of the Commissioner for Trademarks or a federal court.
- **Second Filing Deadline:** You must file a Declaration of Use (or Excusable Nonuse) and an Application for Renewal between the 9th and 10th years after the registration date.* See 15 U.S.C. §1059.

Requirements in Successive Ten-Year Periods*

What and When to File:

- You must file a Declaration of Use (or Excusable Nonuse) and an Application for Renewal between every 9th and 10th-year period, calculated from the registration date.*

Grace Period Filings*

The above documents will be accepted as timely if filed within six months after the deadlines listed above with the payment of an additional fee.

***ATTENTION MADRID PROTOCOL REGISTRANTS:** The holder of an international registration with an extension of protection to the United States under the Madrid Protocol must timely file the Declarations of Use (or Excusable Nonuse) referenced above directly with the United States Patent and Trademark Office (USPTO). The time periods for filing are based on the U.S. registration date (not the international registration date). The deadlines and grace periods for the Declarations of Use (or Excusable Nonuse) are identical to those for nationally issued registrations. See 15 U.S.C. §§1058, 1141k. However, owners of international registrations do not file renewal applications at the USPTO. Instead, the holder must file a renewal of the underlying international registration at the International Bureau of the World Intellectual Property Organization, under Article 7 of the Madrid Protocol, before the expiration of each ten-year term of protection, calculated from the date of the international registration. See 15 U.S.C. §1141j. For more information and renewal forms for the international registration, see <http://www.wipo.int/madrid/en/>.

NOTE: Fees and requirements for maintaining registrations are subject to change. Please check the USPTO website for further information. With the exception of renewal applications for registered extensions of protection, you can file the registration maintenance documents referenced above online at <http://www.uspto.gov>.

NOTE: A courtesy e-mail reminder of USPTO maintenance filing deadlines will be sent to trademark owners/holders who authorize e-mail communication and maintain a current e-mail address with the USPTO. To ensure that e-mail is authorized and your address is current, please use the Trademark Electronic Application System (TEAS) Correspondence Address and Change of Owner Address Forms available at <http://www.uspto.gov>.